



General Description:

- (1) Chip Dimension
Chip Size= 45.0 mil x 45.0 mil (1170um x 1170um)
Chip Thickness= 150±10μm
P Bonding Pad= 100±10μm
N Bonding Pad= 100±10μm
- (2) Electrode:
P (Anode) → Au
N (Cathode) → Au
- (3) Structure:
Backside metal reflector
SiO₂ Passivated surface

Electro-optical Characteristics

Parameter	Symbol	Min.	Typ.	Max.	Unit	Condition
Forward Voltage	V _F	-	3.4	4.0	V	I _F =350mA
Dominant Wavelength	λ _D	450	-	467.5	nm	I _F =350mA
Reverse Current	I _R	0	-	2	μA	V _R =-5V

Luminous Intensity(I _v) mcd at I _F =350mA	Dominant Wavelength(nm)											
	445~447.5	447.5~450	450~452.5	452.5~455	455~457.5	457.5~460	460~462.5	462.5~465	465~467.5	467.5~470	470~472.5	472.5~475
2200-2400			*									
2400-2600			*	*								
2600-2800			*	*	*							
2800-3000				*	*	*						
3000-3300					*	*	*					
3300-3600						*	*	*				
3600-3900						*	*	*	*			
3900-4200							*	*	*			
4200-4500								*	*			

Features:

1. High Luminous Intensity
2. Long Operation Life
3. High Current; Pulse Operation
4. Indoor/Outdoor Applications

Notes:

1. Dominant wavelength includes an error of ± 1nm
2. Luminous intensity includes an error of ±10%
3. Luminous intensity is measured on bare chip
4. InGaN LED is sensitive to ESD

